

Physics- and process-based bipolar transistor modeling for integrated circuit design

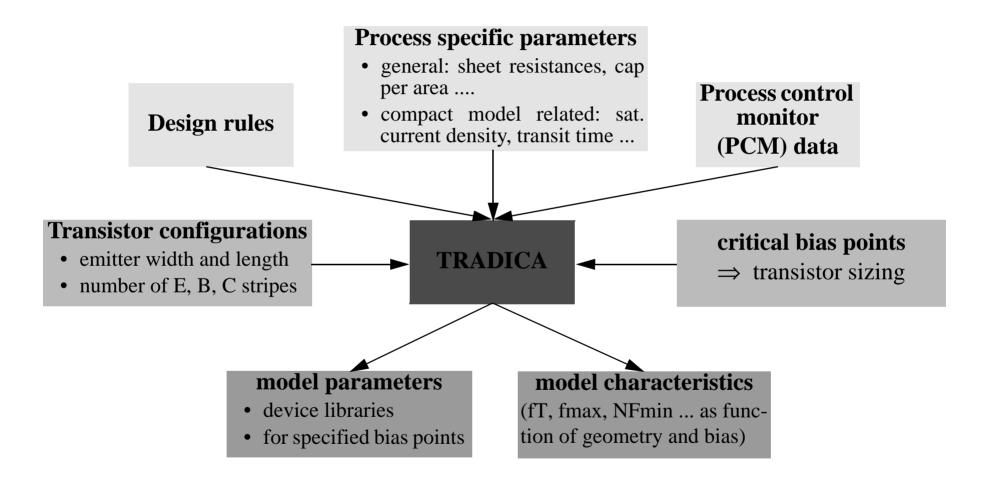
## **Motivation**

- Increasing demand on circuit performance  $\rightarrow$  often requires transistor operation close to the process performance limit  $\Rightarrow$  design measures:
  - careful circuit optimization through proper transistor sizing
  - process variations need to be included
- Large variety of circuit applications → overall required number of transistor configurations<sup>1</sup> can become very large (>100) ⇒ need geometry scalable compact models
- Reduce time-to-market: start circuit design during process development (*concurrent engineering*)

  ⇒ predicted but consistent model parameters and flexible parameter generation
- Align process development with product (design) needs
  - ⇒ quick evaluation of process change impact on electrical device and circuit performance
- Include process tolerances in design:
  - statistical modeling
  - matching

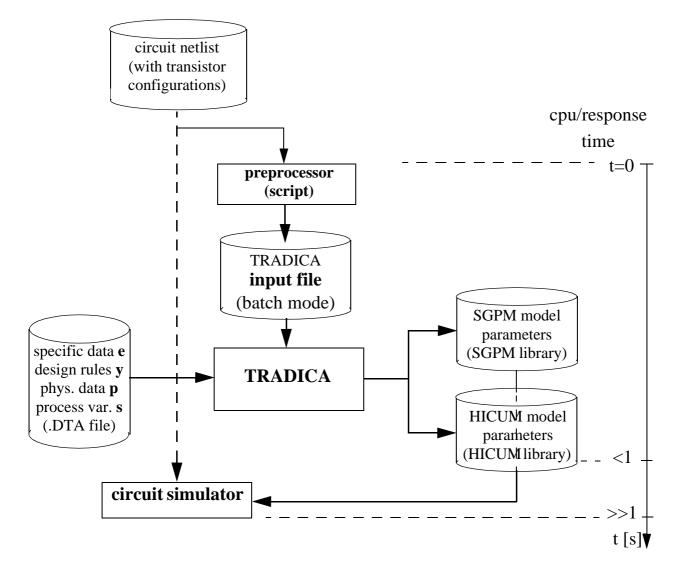
<sup>1.</sup> defined by emitter dimensions  $b_{E0}$  and  $l_{E0}$  ( $\ge b_{E0}$ ), number of emitter, base, and collector fingers/contacts and their spatial arrangement

#### **TRADICA overview**



## Integration of TRADICA in RF design system

- Benefits:
  - circuit optimization via consistently scalable transistor models
  - statistical and matching simulation
  - parameter transfer via single "technology" file (xxxx.DTA)
    - ⇒ significant enhancement of functionality for design at reduced maintenance effort for foundry
- Integration scheme:



### **Program features**

- Generation of consistent sets of geometry scalable compact model parameters for
  - HICUM
  - SGPM

for each: hierarchy of equivalent circuits with different complexity

- Statistical modeling capability
  - generation of skewed model parameter sets
  - determination of corner-case parameter sets
- Transistor sizing
- Automatic extraction of specific SGPM parameters from specific HICUM parameters
- General features:
  - user friendly interactive operation
  - batch operation (for integration in extraction and design systems)
  - Manual and installation guide available
  - platforms: UNIX, Windows

# **Distribution list**

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Agere
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Alcatel

Alpha (formerly Conexant's III-V division)

**Atmel** 

**Conexant** 

**Cypress** 

**IBM** 

IIT

**Infineon** 

Jazz

Maxim

**SiliconWave** 

**STMicroelectronics**